

for 10/683, 668

Searches for User *ceverhart* (Count = 11632)

Queries 11583 through 11632.

<input type="button" value="Find"/>	<input type="text"/>		
<input type="button" value="Newest"/>	<input type="button" value="Oldest"/>	<input type="button" value="Next"/>	<input type="button" value="Oldest"/>
<input type="button" value="Edit"/>	<input type="button" value="Help"/>	<input type="button" value="Return"/>	

S #	Updt	Database	Query	Time	Comment
<u>S11632</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(4983226 5506168 5561073 5780346 5786263 5795811 5801082 5940717 5989977 5989978 6057209)![pn]	2005- 03-15 11:17:01	
<u>S11631</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	6200881	2005- 03-15 11:15:33	
<u>S11630</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	((polysilicon or (amorphous adj silicon)) same (protect\$5 adj4 nitride)) and ((isolation adj trench) same stress)	2005- 03-15 10:25:09	
<u>S11629</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(polysilicon or (amorphous adj silicon)) same (protect\$5 adj3 stress adj relief adj layer)	2005- 03-15 10:24:12	
<u>S11628</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(polysilicon or (amorphous adj silicon)) near4 (protect\$5 adj3 stress adj relief adj layer)	2005- 03-15 10:23:42	
<u>S11627</u>	<u>U</u>	USPT	6717231 and (56	2005-	

		5753562
		5801083
		5834358
		5837595
		5837612
		5858842
		5863827
		5872045
		5882982
		5885883
		5940716
		6140208
		6187651
		6251746
		6255176
		6255194)![pn]
<u>S11619</u>	<u>U</u>	USPT (6683354 or 2005- 6461937) and 03-15 ((recess adj 09:49:14 inhibiting) same silicon)
<u>S11618</u>	<u>U</u>	USPT (6683354 or 2005- 6461937) and 03-15 (recess adj 09:46:38 inhibiting)
<u>S11617</u>	<u>U</u>	USPT (6683354 or 2005- 6461937) and 03-15 (polysilicon or 09:45:05 silicon)
<u>S11616</u>	<u>U</u>	USPT (6683354 or 2005- 6461937) and 03-15 (polysilicon or 09:45:00 silicon)
<u>S11615</u>	<u>U</u>	PGPB,USPT,DWPI (1284499 or 2005- 5929650 or 03-13 20030034489) 12:55:08 and pad\$1
<u>S11614</u>	<u>U</u>	PGPB,USPT,DWPI (1284499 or 2005- 5929650 or 03-13 20030034489) 12:54:15 and memory
<u>S11613</u>	<u>U</u>	USPT,DWPI (1284499 or 2005- 5929650) and 03-13 scribe 12:53:03
<u>S11612</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (5563343 2005- 5650354 03-12 5665622 15:59:36 5665632 5665633

		5756389	
		5834359	
		5926713	
		5943578	
		6130139	
		6187683	
		6204149	
		6245642	
		6380078	
		6391792	
		6444517	
		6482716)![pn]	
<u>S11611</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD 6613644	2005- 03-12 15:59:25
<u>S11610</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (narrow adj trenches) same ((polysilicon or silicon) same sacrificial	2005- 03-12 15:28:26
<u>S11609</u>	<u>U</u>	USPT (6677634 or 6627506) and ((polysilicon or silicon) same sacrificial)	2005- 03-12 15:24:20
<u>S11608</u>	<u>U</u>	USPT (6677634 or 6627506) and ((polysilicon or silicon) near4 sacrificial)	2005- 03-12 15:24:00
<u>S11607</u>	<u>U</u>	USPT (6677634 or 6627506) and ((polysilicon or silicon) adj (liner or lining or layer))	2005- 03-12 15:22:18
<u>S11606</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (sacrificial adj2 (polysilicon or silicon) adj (lining or liner or layer)) same trench	2005- 03-12 15:03:28
<u>S11605</u>	<u>U</u>	USPT ((recess\$3 or etch\$4) near4 ((polysilicon or silicon) adj (lining or liner)))	2005- 03-12 15:00:00
<u>S11604</u>	<u>U</u>	USPT 6607967 and ((polysilicon or	2005- 03-12

			14:57:12
S11599	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD trench\$2 and ((polysilicon or silicon) adj (lining or liner)) and ((liner or lining) near3 etch\$4)	2005-03-12 14:51:40
S11598	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD trench\$2 and ((polysilicon or silicon) adj (lining or liner)) and ((liner or lining) near3 recessed)	2005-03-12 14:51:25
S11597	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD trench\$2 and ((polysilicon or silicon) adj (lining or liner))	2005-03-12 14:51:00
S11596	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD trench\$2 and ((polysilicon or silicon) adj stress adj (lining or liner))	2005-03-12 14:50:45
S11595	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD trench\$2 and ((polysilicon or silicon) adj stress adj relief)	2005-03-12 14:48:39
S11594	U	USPT 6461937 and (polysilicon or silicon)	2005-03-12 14:43:26
S11593	U	USPT 5869384 and ((silicon or polysilicon))	2005-03-12 14:16:15
S11592	U	USPT 6074930 and ((silicon or polysilicon))	2005-03-12 14:15:28
S11591	U	USPT 6074930 and ((silicon or polysilicon) adj (liner or lining))	2005-03-12 14:15:11
S11590	U	USPT (4571819 4952524 5189501 5190889 5206182 5447884 5521422 5554256)	2005-03-12 13:55:17